



Correction

# Correction: Zhou et al. Effect of Zirconium Doping on Electrical Properties of Aluminum Oxide Dielectric Layer by Spin Coating Method with Low Temperature Preparation. *Coatings* 2020, 10, 620

Yue Zhou <sup>1</sup>, Zhihao Liang <sup>1</sup>, Rihui Yao <sup>1,\*</sup> , Wencai Zuo <sup>1</sup>, Shangxiong Zhou <sup>1</sup>, Zhennan Zhu <sup>1</sup>, Yiping Wang <sup>2</sup>, Tian Qiu <sup>3</sup>, Honglong Ning <sup>1,\*</sup>  and Junbiao Peng <sup>1</sup>

<sup>1</sup> State Key Laboratory of Luminescent Materials and Devices, Institute of Polymer Optoelectronic Materials and Devices, South China University of Technology, Guangzhou 510641, China; 201730341030@mail.scut.edu.cn (Y.Z.); 201530291443@mail.scut.edu.cn (Z.L.); 201730321407@mail.scut.edu.cn (W.Z.); 201820117973@mail.scut.edu.cn (S.Z.); mszhuzn@mail.scut.edu.cn (Z.Z.); psjbpeng@scut.edu.cn (J.P.)

<sup>2</sup> State Key Laboratory of Mechanical Structural Mechanics and Control, Nanjing University of Aeronautics and Astronautics, Nanjing 210016, China; yipingwang@nuaa.edu.cn

<sup>3</sup> Faculty of Intelligent Manufacturing, Wuyi University, Jiangmen 529000, China; timeqiu@hotmail.com

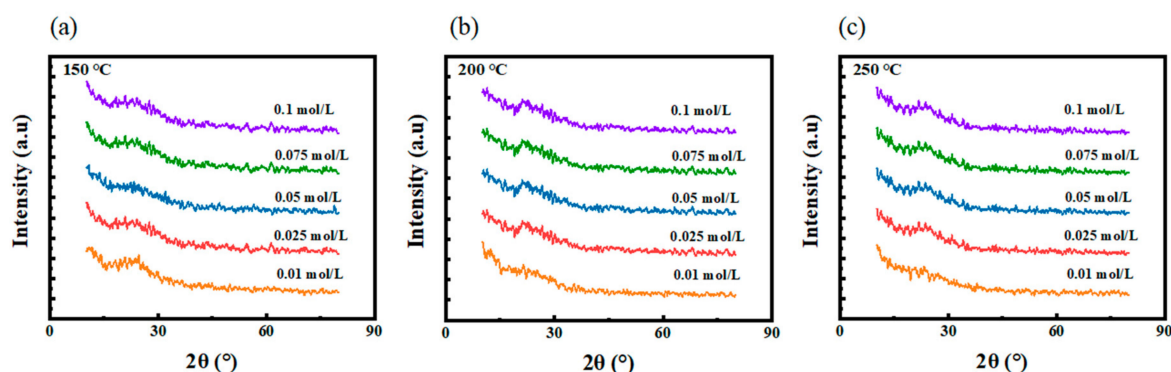
\* Correspondence: yaorihui@scut.edu.cn (R.Y.); ninghl@scut.edu.cn (H.N.)

Received: 16 October 2020; Accepted: 21 October 2020; Published: 21 October 2020



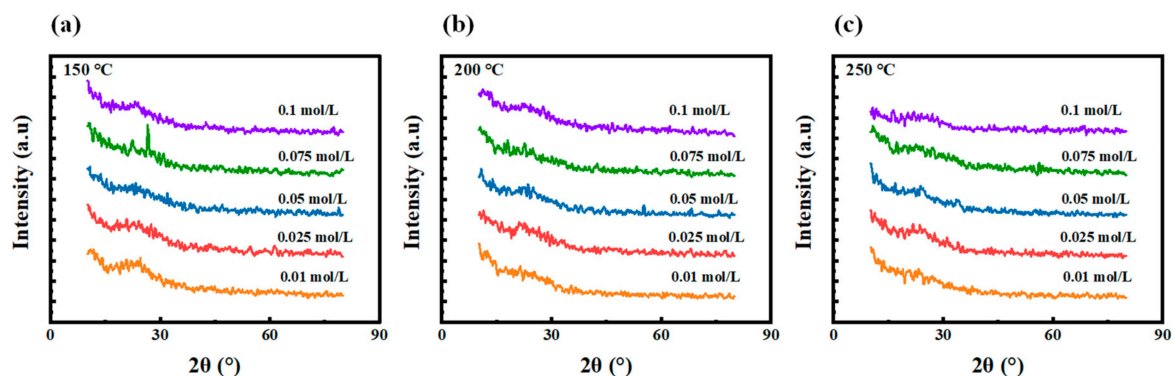
The authors wish to make the following corrections to this paper [1]:

While this manuscript was in preparation, there are some data processing errors leading to some drawing mistakes. Replace:



**Figure 2.** X-ray diffraction (XRD) spectra of Zr–AlO<sub>x</sub> films with different Zr concentrations: (a) annealing at 150 °C, (b) annealing at 200 °C, and (c) annealing at 250 °C.

with



**Figure 2.** X-ray diffraction (XRD) spectra of Zr-AlO<sub>x</sub> films with different Zr concentrations: (a) annealing at 150 °C, (b) annealing at 200 °C, and (c) annealing at 250 °C.

The authors would like to apologize for any inconvenience caused to the readers by these changes.

## Reference

1. Zhou, Y.; Liang, Z.; Yao, R.; Zuo, W.; Zhou, S.; Zhu, Z.; Wang, Y.; Qiu, T.; Ning, H.; Peng, J. Effect of Zirconium Doping on Electrical Properties of Aluminum Oxide Dielectric Layer by Spin Coating Method with Low Temperature Preparation. *Coatings* **2020**, *10*, 620. [[CrossRef](#)]

**Publisher's Note:** MDPI stays neutral with regard to jurisdictional claims in published maps and institutional affiliations.



© 2020 by the authors. Licensee MDPI, Basel, Switzerland. This article is an open access article distributed under the terms and conditions of the Creative Commons Attribution (CC BY) license (<http://creativecommons.org/licenses/by/4.0/>).